

PATENT

**RESPONSE UNDER 37 C.F.R. 1.116 - EXPEDITED  
PROCEDURE - EXAMINING GROUP 2891**

**IN THE UNITED STATES PATENT AND TRADEMARK OFFICE**

Appl. No.: 10/808,692 Confirmation No.: 6062  
Applicant(s): Ogihara et al.  
Filed: 03/25/2004  
Art Unit: 2891  
Examiner: A. Sarkar  
Title: COMPOSITION FOR FORMING POROUS FILM, POROUS FILM  
AND METHOD FOR FORMING THE SAME, INTERLEVEL INSULATOR  
FILM AND SEMICONDUCTOR DEVICE

*Do not  
enter  
AKS  
5/25/06*

Docket No.: 035576/276101  
Customer No.: 00826

Mail Stop AF  
Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

**REPLY AFTER FINAL UNDER 37 CFR § 1.116**

Sir:

In response to the final Office Action dated March 20, 2006, please consider the following remarks:

Remarks/Arguments begin on page 2 of this paper.